



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re:

Iwabuchi, et al.

Confirmation No.: 6716

Appl. No.:

10/706,863

Group Art Unit: 2826

Filed:

10//00,803

Examiner:

Quach, Tuan N.

For:

November 12, 2003

COMPOSITION FOR FORMING POROUS FILM, POROUS FILM

AND METHOD FOR FORMING THE SAME, INTERLEVEL INSULATOR

FILM, AND SEMICONDUCTOR DEVICE

Mail Stop Amendment Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

Sir:

Attached is a list of documents on form PTO-1449 along with a copy of any cited foreign patent documents and non-patent literature document in accordance with 37 CFR 1.98(a)(2). Also enclosed is a translation or a concise explanation of each non-English language document.

It is requested that the Examiner consider these documents and officially make them of record in accordance with the provisions of 37 C.F.R. § 1.97 and Section 609 of the MPEP. By identifying the listed documents, Applicant in no way makes any admission as to the prior art status of the listed documents, but is instead identifying the listed documents for the sake of full disclosure.

This Information Disclosure Statement is submitted in accordance with 37 C.F.R. § 1.97(c), before final Office Action or Allowance, whichever is earlier.

In accordance with the requirements of 37 C.F.R. § 1.97(c), the following statement as specified in 37 C.F.R. § 1.97(e) is made:

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A check for the \$180.00 fee specified in 37 C.F.R. § 1.17(p) is enclosed. The Commissioner is authorized to charge any additional fee, or credit any refund, to our Deposit Account No. 16-0605.

Respectfully submitted,

Cynthia V. Hall Registration No. 56,544

Customer No. 00826 ALSTON & BIRD LLP

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CERTIFICATE OF MAILING

I hereby certify that this correspondence is being deposited with the United States Postal Service with sufficient postage as first class mail in an envelope addressed to: Mail Stop Amendment, Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450, on January 18, 2006.

Chana Maara

Shana Moore

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Substitute for form 1449/PTO (Refried 07/2005)

INFORMATION DISCLOSURE STATEMENT BY APPLICANT

(Use as many sheets as necessary)

Sheet of

		Complete if Known
	Application Number	10/706,863
	Filing Date	November 12, 2003
	First Named Inventor	Iwabuchi et al.
	Group Art Unit	2826
	Examiner Name	Quach, Tuan N.
	Attorney Docket Number	035576/271460

U. S. PATENT DOCUMENTS						
Examiner Initials*			Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages of Relevant Figures Appear	
	13	US-2002/0020327	02-21-2002	Hayashi, et al.		
	14	US-2002/0098279 A1	07-25-2002	Lyu, et al.		
	15	US-2002/0155053 A1	10-24-2002	Nishiyama, et al.		
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Examiner	Date	
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^{*}Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

Complete if Known Substitute for form 1449/PTO Application Number 10/706,863 (Revised 07/2005) Filing Date November 12, 2003 First Named Inventor Iwabuchi et al. INFORMATION DISCLOSURE Group Art Unit 2826 STATEMENT BY APPLICANT (Use as many sheets as necessary) Quach, Tuan N. Examiner Name 035576/271460 Attorney Docket Number Sheet of FOREIGN PATENT DOCUMENTS Pages, Columns, English Foreign Patent Document Lines, Where Examiner Cite Publication Date Name of Patentee or Language Relevant Passages MM-DD-YYYY Initials No. Country Code - Number Kind Applicant of Cited Document Translation or Relevant Figures Code (if known) Attached Appear Shin-Etsu Chemical Co., EP 1223192 07-17-2002 35 Ltd. Samsung Electronics 36 EP 1245642 10-02-2002 Co., Ltd. 37 JP 05-125191 05-21-1993 Kanegafuchi Chem. Ind. Abstract Co. Ltd. only 38 JP 63-015355 04-04-1988 Tama Chemical Co. Ltd. Abstract only 39 JP 09-194298 07-29-1997 Rikagaku Kenkyusho Abstract only 40 JP 2000-309751 11-07-2000 Abstract JSR Corp. only Abstract 41 JP 2000-309753 11-07-2000 JSR Corp. only 42 12-12-2000 Abstract JP 2000-345041 JSR Corp. Abstract 43 JP 2000-044875 02-15-2000 JSR Corp. only 44 Abstract JP 2001-115028 04-24-2001 JSR Corp. only JP 2001-115029 45 04-24-2001 Abstract JSR Corp. only 46 JP 2001-130911 05-15-2001 Japan Chemical Abstract Innovation Institute only 47 JP 2001-157815 06-12-2001 Toyota Central Res. & Abstract Dev. Lab Inc. & Denso only Corp.

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Signature	Considered	

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Substitute for form 1449/PTO (Revised 07/2005)					Application Number 10/706,863				
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INFORMATION DISCLOSURE			First Named Inv	entor	Iwabuchi et al.				
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STATEMENT BY APPLICANT					Quach, Tuan N.				
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				FO	REIGN PATENT	DOCUM	INTO	······································	
		r —	Foreign Patent l		REIGN PATENT	DOCUMI	INIS	Pages, Columns,	English
Examiner Initials	Cite No.				Publication Date MM-DD-YYYY	1	atentee or of Cited Document	Lines, Where Relevant Passages or Relevant Figures Appear	Language Translation Attached
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					OTHER DOCU	JMENTS			
Examiner	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and-or country where published.					English Language Translation Attached			
	59	Con		Siloxane A	esis Of Hybrid Inorg and Organosiloxane				
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niner	Date
Signature	Considered

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